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NANONEX SPONSORSHIP AT NNT 2006

Princeton, NJ, June 20, 2006: Nanonex Corporation, the leader in nanoimprint solution and applications with the longest history, is sponsoring of the 5th International Conference on Nanoimprint and Nanoprint Technology.

Nanonex is pleased to provide support to NNT, the foremost academic conference on advanced lithography technologies of Nanoprint and Nanoimprint. This year's conference will be held in beautiful San Francisco, CA, November 15-17. Please visit <http://www.nntconf.org/> for more information.

“NNT has proven to be the forum of choice for presentation of advanced nanolithography technologies and applications, and this years 5th annual meeting will again highlight the enormous progress being made” – Larry Koecher, COO, Nanonex Corp.

Conference Chair for this year's meeting is Dr. Christie Marrian of Spansion Technologies.

About Nanonex Corp.

Nanonex, a pioneer and a leader in nanoimprint, provides a complete line of nanoimprint lithography (NIL) technology solutions including tools, masks, and processes. Nanonex NIL solutions offer sub 10 nm feature resolution, 3D patterning, large area uniformity, accurate overlay alignment, high-throughput, and low cost. Nanonex NIL solutions include all forms of nanoimprinting, such as thermal plastic, uv-curable, thermal curable, and direct imprinting (embossing). Nanonex NIL solutions can meet the needs of a broad spectrum of markets, such as optical devices, displays, data storage, biotech, IC, chemical synthesis, and advanced materials. Visit www.nanonex.com for additional information.